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S. Patent Application SN 09/764,031
New Claims 11-26

11. A process for production of a sintered oxide ceramic of composition $Ce_xM_yD_zO_{2-a}$ with dense structure without open porosity or with a predetermined porosity comprising the steps of:

using a first doping element M selected from the group consisting of rear earths, but wherein $M \neq Ce$, alkali metals, earth alkali metals, and Ga;

using an educt with a second doping element D of at least one metal, but wherein $D \neq M$, selected from the group consisting of Cu, Co, Fe, Ni, and Mn wherein second doping element D is of submicron particle size or is a salt solution; and

sintering the educts at a temperature between 750-1200°C to form said oxide ceramic having a grain size no greater than 0.5 μm and wherein the mol fractions used range from $0.5 \leq x \leq 1$ for Ce, $0 \leq y \leq 0.5$ for first doping element M, and $0 < z \leq 0.05$ for second doping element D.

12. The process according to claim 11, characterized in that first doping material M is taken from the group La, Pr, Nd, Pm, Sm, Eu, Gd, Tb, Dy, Ho, Er, Tm, Yb, Lu; Ca, Sr, Ba; Sc, Y.

13. The process according to claim 11 wherein said mol fraction of z ranges from $0.001 \leq z \leq 0.02$.

14. The process according to claim 11 wherein said educts have a mean grain size not greater than $0.1 \mu\text{m}$.

15. The process according to claim 14 wherein said educts have a mean grain size range of $0.01 - 0.05 \mu\text{m}$.

16. The process according to claim 11 wherein said sintering is performed at a temperature in the range of $800 - 1200^\circ$

17. The process according to claim 11 wherein said sintering is performed at a temperature in the range of 850 to 1100°C .

18. The process according to claim 11 comprising the additional steps of:

monitoring a temperature rise of said composition;

interrupting said temperature rise at a determined

temperature; and

terminating the sintering.

19. The process according to claim 11 wherein sintering occurs at a heating rate in the range of 0.5 - 20°C/min.

20. The process according to claim 11 wherein sintering occurs at a heating rate in the range of 1 - 10°C/min.

21. The process according to claim 11 wherein sintering continues until a density of at least around 98% of the theoretically possible density is reached.

22. The process according to claim 11 wherein sintering continues until a density of at least around 99% of the theoretically possible density is reached.

23. The process according to claim 11 wherein said sintering comprises a holding time between 1-2 hours.

24. The process according to claim 11 wherein said sintering comprises a holding time of at least 0.25 hours.

25. The process according to claim 11 comprising the additional step of grounding said educts wet and/or dry and calcinated.

26. Process according to claim 1 characterized in that the educts are precipitated, filtered and calcinated jointly as inorganic salts.